Cycloreversion of 2,3-Disilabicyclo[2.2.2]octa-5,7-dienes Induced by Electron-Transfer

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Synopsis. Photolysis of 1-phenyl-2,2,3,3-tetramethyl-2, 3-disilabicyclo[2.2.2]octa-5,7-diene (1) with 9,10-dicyanoan-thracene as a sensitizer yielded biphenyl as a tetramethyl-disilene extrusion product. The mass spectrum of 1 provides access to the understanding of the reaction mechanism involving cycloreversion of a cation radical of 1.

2,3-Disilabicyclo[2.2.2]octa-5,7-dienes 1—3 are known to produce transient Si–Si double bonds (disilenes)¹⁾ on thermolysis.²⁾ Meanwhile, it has been demonstrated that 2 is photochemically reactive to undergo both disilene extrusion and intramolecular rearrangement.³⁾ Recently, it has been reported that anion-catalyzed extrusion of disilene units from some derivatives of 1 yields ordered and monodispersed polysilane high polymers.⁴⁾ However, no attention has been focused on their electron-donating characteristics. As a part of our continuing research for the electron transfer chemistry of organosilicon compounds,⁵⁾ we now report a novel cycloreversion of 1—3 induced by electron transfer.

By cyclic voltammetry, it is shown that 1—3 are fairly good electron donors compared with usual allylsilanes (Table 1).6 Irradiation of 1 in a mixed solvent of CH₃CN/CH₂Cl₂ in the presence of 9.10-dicvanoanthracene (DCA) with two 500 W tungsten-halogen lamps in a Pyrex tube produced biphenyl (4) in a quantitative yield and a complex polymeric mixture containing silylmethyl units. Since the reaction did not occur without DCA, it is clear that DCA should be excited first by irradiation and acts as a sensitizer. Very similar results were obtained with 2 and 3. The free energy changes (ΔG) calculated by the Rehm-Weller equation⁷⁾ are indicative of highly exothermic electron transfer from 1—3 to the excited singlet state of DCA. Furthermore, the DCA fluorescence was efficiently quenched by 1—3 with diffusion-controlled rates (Table 1). In addition, when 10 mol% of (p-BrC₆H₄)₃NSbCl₆,⁸⁾ an one-electron oxidizing reagent, was added to 1—3 in CH₂Cl₂ under a N₂ atmosphere caused the cycloreversion to give 4—6, respectively (Table 2). Thus it is indicated that electron-transfer process affording cation radicals of 1—3 is operative in the cycloreversion. However, every effort of trapping the extruded disilene units using benzophenone,9) bis(trimethylsilyl)acetylene,2b,3c,10) and 2,3-dimethylbutadiene,111) which are usual traps for transient disilenes, was unsuccessful. Although the electron-transfer cleavage of Si–Si σ bonds with CCl₄ has been reported previously, 5a) DCA-sensitized photoreaction of 1 in the presence of CCl₄ afforded none of identifiable chlorinated products (Chart 1).

Meanwhile, addition of an equimolar amount of tetracyanoethylene (TCNE) to 1-3 in CH₂Cl₂ at room temperature also resulted in the cycloreversion affording 4, 5, and 7 (a TCNE adduct of 6), 12) respectively. Many examples of charge-transfer (CT) complexes between organosilicon compounds and TCNE have been reported.¹³⁾ Whereas a CT band of 3 and TCNE in CH₂Cl₂ appeared at 649 nm as expected, those of 1 and 2 could not be observed probably due to rapid decomposition of 1 and 2 induced by electron transfer. These results are rationalized by electron transfer from 1—3 to TCNE induced by the CT complexing. 14) In the case of 1, a tetrasiladioxane derivative 8¹⁵⁾ was obtained. Although the mechanism of the formation of 8 remains unclear at this moment, one possible explanation involves hydrolysis of 1 with a trace amount of H₂O under the reaction conditions and subsequent condensation since the yield of 8 increased when a mixture of THF/H₂O was used as a solvent.

To gain insight into the reaction mechanism, mass spectral fragmentations of 1—3 were investigated. ^{5g,5h)} As shown in Scheme 1 and Table 3, the mass spectra of 1—3 show moderate intensities of the peaks due to M^{+•}, (Me₂SiSiMe₂; 9)^{+•} as reported by Roark and Peddle. ^{2a)} The presence of two fragmentation proc essed, namely, M^{+•} to 9^{+•}, 9^{+•} to (Me₃Si; 10)⁺ and (Me₂SiSiMe; 11)⁺, are indicated by linked scanning (both B²/E and B/E constant spectra). ^{5g,5h)} This fragmentation suggests that disilene cation radical 9^{+•} is

Table 1. Oxidation Potentials, Calculated ΔG values for the One-Electron Transfer Process from 1—3 to $^{1}DCA^{*}$, and Rate Constants for the Fluorescence Quenching of DCA

Substrate	$E_{ m ox}{}^{ m a)}/{ m V}$	$\Delta G^{ m b)}/{ m kJmol^{-1}}$	$k_{\rm q}^{\rm c)} \times 10^{-10}/{\rm dm}^3 {\rm mol}^{-1} {\rm s}^{-1}$
1	0.42	-170.3	2.50
2	0.60	-153.1	2.10
3	0.80	-133.9	1.43

a) Oxidation potentials vs. SCE in CH_3CN . b) Free energy changes calculated by the Rehm–Weller equation. ⁷⁾ c) Rate constants for fluorescence quenching calculated from the Stern–Volmer plots.

Table 2. Electron Transfer Induced Cycloreversion of 1—3

Substrate	Condition	Time	Conversion/%	Products (Yields/%) ^{a)}
1	$h\nu/{\rm DCA/CH_3CN/CH_2Cl_2}$	15 min	100	4 (85)
2	$h u/{ m DCA/CH_3CN/CH_2Cl_2}$	1 h	39	5 (100)
3	$h u/{ m DCA/CH_3CN/CH_2Cl_2}$	1 h	30	6 (61)
1	$(p\text{-BrC}_6\text{H}_4)_3\text{NSbCl}_6/\text{CH}_2\text{Cl}_2/-78^{\circ}\text{C}$	3 h	100	4 (73)
2	$(p\text{-BrC}_6\text{H}_4)_3\text{NSbCl}_6/\text{CH}_2\text{Cl}_2/-78^\circ\text{C}$	3.5 h	76	5 (88)
3	$(p\text{-BrC}_6\text{H}_4)_3\text{NSbCl}_6/\text{CH}_2\text{Cl}_2/-78^{\circ}\text{C}$	3.5 h	21	6 (100)
1	$TCNE/CH_2Cl_2$	$10 \min$	100	4 (96)
2	TCNE/CH ₂ Cl ₂	$10 \min$	100	5 (100)
3	$TCNE/CH_2Cl_2$	1.5 h	23	7 (100) b)

a) Conversion yields determined by GLC. b) By NMR.

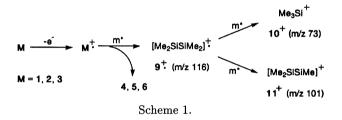


Table 3. MS peak intensities of 1-3

M	m/z 116	m/z 73	m/z 101
1	100	36	13
2	100	40	12
3	100	32	9

the probable intermediate in the electron transfer induced cycloreversion of 1—3. These selective C–Si bond cleavages of 1—3 are of particular interest since one electron oxidation of polysilane usually results in the facile Si–Si cleavage. $^{5a,5b,5g,16)}$

Experimental

NMR spectra were recorded with a JEOL JNM-GX270 spectrometer. Deuteriated chloroform and benzene were used as the solvent. Mass spectral data were obtained on a Shimadzu QP-1000 and a Hitachi M-80B mass spectrometers. UV-visible spectra were obtained with a JASCO Ubest 30 spectrometer. GLC-analyses were carried out on a Shimadzu GC-14A equipped with a 0.25 mm \times 25 m CBPl capillary column. Cyclic voltammograms of 1-3 were obtained on 0.1 M $n\text{-Bu}_4\text{NClO}_4/\text{CH}_2\text{Cl}_2$ solution (1 M=1 mol dm $^{-3}$) (vs. SCE; scan rate, 200 mV s $^{-1}$; Nikkoh Keisoku Ltd., a potentiostat/galvanostat NPGS-301 and a potential

sweeper NPS-2). The ΔG values were calculated according to the Rehm-Weller equation $(\Delta G (\text{kcal mol}^{-1}) = 23.06 - [E(D/D^+) - E(A^-/A) - e_0^2/\varepsilon a - \Delta E_{\text{o,o}}])^{7)}$ by using the excited singlet energies of DCA (2.89 V), the reduction potentials of DCA (-0.98 V vs. SCE),¹⁷⁾ and 0.06 eV for $e_0^2/\varepsilon a$. The rate constants (k_q) for DCA fluorescence quenching with 1—3 were measured by using a JASCO FP-550 fluorescence spectrometer. The k_q values were calculated from the literature value of τ (15.3 ns) for DCA.¹⁷⁾ Irradiation was carried out by two 500-W tungsten-halogen lamps using a Pyrex filter in a water bath while N₂ passed through the photolysate.

Materials. DCA (Tokyo Kasei) and $(p\text{-BrC}_6H_4)_3$ NSbCl₆ (Aldrich) were used as received. TCNE (Tokyo Kasei) was used after sublimination. Compounds 1—3 were prepared according to the literature.^{2a)}

DCA-Sensitized Photoreactions of 1—3. In a typical experiment, 1 $(1.7\times10^{-2} \text{ M})$ was dissolved in a mixed solvent of CH₃CN and CH₂Cl₂ (4:1) with DCA $(1.3\times10^{-3} \text{ M})$ as a sensitizer, and this solution was photolyzed. The reaction was monitored by GLC. Formation of 4 was confirmed by comparison of its retention time on GLC with that of the authentic sample and GC-MS analysis, and the yield of 4 was also determined by GLC.

Reactions of 1—3 with $(p\text{-BrC}_6H_4)_3NSbCl_6$. In a typical experiment, 10 mol% of $(p\text{-BrC}_6H_4)_3NSbCl_6$ in CH₂Cl₂ (5 ml) was added to a CH₂Cl₂ (20 ml) solution of 1 (0.5 mmol) at -78° C in the dark under a N₂ atmosphere. After stirring 3 h, 1 was completely consumed. The yield of 4 was determined by GLC analysis by comparing with the authentic samples.

Reactions of 1—3 with TCNE. In a typical experiment, an equimolar amount of TCNE was added to a CH_2Cl_2 (20 ml) solution of 1 (0.5 mmol) at room temperature in the dark under a N_2 atmosphere. After stirring

10 min, and the yield of **4** was determined by GLC. The formation of $7^{12)}$ and $8^{15)}$ (in the cases of **1** and **3**, respectively) was confirmed by comparison of the NMR spectra with those of authentic samples.

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